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APPLICATION NO	TION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/826,733		04/16/2004	Masataka Shinoda	075834.00485 1364	
33448	7590	03/09/2006		EXAMINER	
ROBERT			GOMA, TAWFIK A		
LEWIS T. STEADMAN TREXLER, BUSHNELL, GLANGLORGI, BLACKSTONE & MARR				ART UNIT	PAPER NUMBER
105 WEST	ADAMS	STREET, SUITE 360	2653		
CHICAGO), IL 606	503-6299	DATE MAILED: 03/09/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	No. Applicant(s)					
Office Action Summan	10/826,733	SHINODA, MASATAKA					
Office Action Summary	Examiner	Art Unit					
	Tawfik Goma	2653					
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim vill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on							
	action is non-final.						
· <u> </u>	, —						
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition of Claims							
4)⊠ Claim(s) <u>1-5</u> is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
S)⊠ Claim(s) <u>1-5</u> is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claim(s) are subject to restriction and/or	r election requirement.						
Application Papers							
9) The specification is objected to by the Examine	r						
10)⊠ The drawing(s) filed on <u>16 April 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correcti	• • • • • • • • • • • • • • • • • • • •						
11) The oath or declaration is objected to by the Ex	· · · · · · · · · · · · · · · · · · ·						
Priority under 35 U.S.C. § 119							
12)⊠ Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a)	-(d) or (f).					
a)⊠ All b) ☐ Some * c) ☐ None of:							
1. Certified copies of the priority documents have been received.							
_	2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage							
·	application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.							
Attachmont/o							
Attachment(s) 1) X Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)					
2) Notice of Praftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	ate					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	·	atent Application (PTO-152)					
Paper No(s)/Mail Date 6) Other:							

DETAILED ACTION

Priority

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-5 are rejected under 35 U.S.C. 103(a) as being unpatentable over Knight et al (US 6243350) in view of Okubo (US 2003/0118936).

Regarding claim 1, Knight discloses an optical recording medium recorded and reproduced with irradiation of light thereon, said irradiation of light being made by an objective lens of which numerical aperture is larger than 1 to record and reproduce recorded pits (col. 9 lines 49-63), comprising at least a silicon layer and a silicon oxide layer being formed from the light irradiation side, in that order (fig. 31, col. 29 lines 44-67 thru col. 30 lines 1-8 and col. 34 lines 47-50). Knight discloses that a dielectric layer (3004) which can be silicon dioxide per another embodiment is formed underneath a recording layer. Although Knight discloses that the any write-once, or phase change material can be used as the recording layer, he fails to disclose a silicon recording layer. In the same field of endeavor, Okubo discloses a recording medium with a silicon recording layer (par. 83). It would have been obvious to one of ordinary skill in

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the art to use a silicon recording layer as taught by Okubo in the recording medium taught by Knight. The rationale is as follows: One of ordinary skill in the art would have been motivated to use a silicon recording layer as a suitable write-once recording material since Knight (col. 29 lines 44-67) suggests using any suitable write-once recording material and Okubo teaches that silicon is a suitable write-once material.

Regarding claim 2, Knight in view of Okubo disclose everything claimed as applied above. Further in regard to claim 2, it is known that silicon is oxidized when irradiated by a recording laser, and pits are formed by changing silicon to silicon-oxide by the recording laser.

Regarding claims 3 and 4, Knight further discloses wherein said silicon layer has formed thereon a protective layer of which refractive index is larger than a numerical aperture of said objective lens (3001, fig. 31, col. 46 lines 47-49 and col. 34 lines 45-47).

Regarding claim 5, claim 5 is rejected for the same reasons as claims 1 and 2 above.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Novotny et al (US 6483801) discloses a recording medium with a protective layer that has an index of refraction greater than the numerical aperture of the objective lens.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tawfik Goma whose telephone number is (571) 272-4206. The examiner can normally be reached on 8:30 am - 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, William Korzuch can be reached on (571) 272-7589. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

T. Goma 3/3/2006

William Horsul